

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants :Syouji NOGAMI et al. Group Art Unit : 2813
Appl. No. : 10/562,235 Examiner : Sonya D. McCall Shepard
Filed : October 31, 2006 Confirmation No. : 8539
For : MANUFACTURING METHOD OF SEMICONDUCTOR WAFER
AND SEMICONDUCTOR WAFER MANUFACTURED BY THIS
METHOD

AMENDMENT UNDER 37 C.F.R. § 1.116

Commissioner for Patents
U.S. Patent and Trademark Office
Customer Service Window, Mail Stop **AMENDMENT**
Randolph Building
401 Dulany Street
Alexandria, VA 22314

OK TO ENTER: /S.M.S./

Sir:

In response to the Final Office Action of February 23, 2010, please amend the above application as follows and reconsider the rejections in view thereof. Inasmuch as this response is filed by April 23, 2010, no fee is due for its consideration.

Amendments to the Claims are reflected in the listing of claims beginning on page 2.

Remarks begin on page 5.